Estimated Award Amount: $750,000
JHU Nomination Limit: 1
For More Detailed Information Click Here

Opportunity Summary:
The Grants to Reduce Domestic Violence, Dating Violence, Sexual Assault, and Stalking on Campus Program (Campus Program) encourages institutions of higher education to develop and strengthen effective security and investigation strategies to combat domestic violence, dating violence, sexual assault, and stalking on campus, develop and strengthen victim services in cases involving such crimes on campus, and develop and strengthen prevention education and awareness programs.

For the list of purpose areas that funds under this program may be used for, please see the full announcement.

Funding levels under this program for FY 2021 are:
1. Individual applicants (a single institution of higher education that proposes to develop and implement project activities on its own campus): Awards will be made up to $300,000 for the entire 36 months.
2. Consortium applicants (two or more institutions of higher education working together to implement the project activities):
   - Two to four institutions: Awards will be made for up to $550,000 for the entire 36 months.
   - Five or more institutions: Awards will be made for up to $750,000 for the entire 36 months.

There will be two pre-application information sessions on 2/4/2021 at 2pm EST and 2/11/2021 at 2pm EST. To register, contact the Campus Program Mailbox at OVW.Campus@usdoj.gov. Registration must be received at least two days prior to the start of the session.

Eligibility & Requirements:
- Recipients of an FY 2019 or FY 2020 award under this program are NOT eligible to apply as the lead applicant. In addition, a campus that was the recipient of an FY 2019 or FY 2020 award as a consortium member is not eligible to apply as the lead or a consortium member on an FY 2021 proposal.
- Applicants are strongly encouraged to submit a Letter of Intent by February 23, 2021 to OVW at OVW.Campus@usdoj.gov. See the OVW website for a sample Letter of Intent.

Internal Nomination Process:
Interested applicants should submit the following documents:

1. JHU Limited Submission Cover Sheet
2. Proposal (maximum of two pages of text only, single spaced: 12-pt font and one-inch margins) (Note: figures, tables, and other reference material may be included in addition to the 2 pg. text limit)
3. Curriculum Vitae of investigator, including current external research support and publications
4. Budget (two pages maximum)

Questions? Comments? Email the Research Development Team at resapp@jhu.edu.